

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|---|------------------|---------|------------------|
| L1 | 5306 | (156/345\$6).ccls. | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:43 |
| L2 | 236 | 1 and ((focus\$3 center\$5 centr\$5) near5 (ring plate flat surface)) and plasma and (wear\$4 worn\$3 erode\$3 ero\$6) and (electrode substrate) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:43 |
| L3 | 8116 | (204/298\$6).ccls. | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:54 |
| L4 | 429 | 3 and ((focus\$3 center\$5 centr\$5) near5 (ring plate flat surface)) and plasma and (wear\$4 worn\$3 erode\$3 ero\$6) and (electrode substrate) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:55 |
| L5 | 377 | 4 not 2 | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:55 |
| L6 | 4981 | (118/715).ccls. or (118/723+). ccls. | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:59 |
| L7 | 65 | 6 and ((focus\$3 center\$5 centr\$5) near5 (ring plate flat surface)) and plasma and (wear\$4 worn\$3 erode\$3 ero\$6) and (electrode substrate) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:05 |
| L8 | 32 | 7 not (5 2) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:00 |
| L9 | 2942 | (315/111\$4).ccls. | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 13:59 |
| L10 | 85 | 9 and ((focus\$3 center\$5 centr\$5) near5 (ring plate flat surface)) and plasma and (wear\$4 worn\$3 erode\$3 ero\$6) and (electrode substrate) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:04 |
| L11 | 67 | 10 not (8 5 2) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:06 |

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|------------------------------------|------------------|---------|------------------|
| L12 | 4446 | ((focus\$3 center\$5 centr\$5) near5 (ring plate flat surface)) and plasma and (wear\$4 worn\$3 erode\$3 ero\$6) and (electrode substrate) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:04 |
| L13 | 1897 | 12 and focus\$3 and (center\$5 centr\$5) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:05 |
| L14 | 323 | 13 and (focus\$3 near5 (ring plate flat surface)) and ((center\$5 centr\$5) near5 (ring plate flat surface)) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:58 |
| L15 | 262 | 14 not (11 8 5 2) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:59 |
| L16 | 3965 | (118/730;728).CCLS. | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:57 |
| L17 | 26 | 16 and (focus\$3 near5 (ring plate flat surface)) and ((center\$5 centr\$5) near5 (ring plate flat surface)) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:59 |
| L18 | 18 | 17 not (15 11 8 5 2) | US-PGPUB; USPAT; EPO; JPO; DERWENT | OR | ON | 2005/08/21 14:59 |